SPIE＇s Photonics West 2003
（発表者：北野利一）
1．会議の概要

- 名称：Photonics West 2003
- 主催：SPIE
- 開催場所：San Jose Convention Center，San Jose California
- 日時：25－31 January 2003
- 主な内容：

BiOS 2003 （Biomedical Optics）
LASE 2003 （Lasers and Applications in Science and Technology） Optoelectronics 2003 （Integrated Optoelectronic Devices）
MF 2003 （Micromachining and Microfabrication）

## 2．発表内容

－Title：Femtosecond laser ablation processing of $\mathrm{x}-\mathrm{cut} \mathrm{LiNbO} 3$ substrates for optical communication devices
－Authors：R．Kitano，K．Ozono，M．Obara，H．Tsuda
－Conference：Laser Applications in Microelectronic and Optoelectronic Manufacturing VIII（4977A）
－Paper Number：4977A－57
－Presentation type：Poster
－Date of Presentation： 28 Jan 2003
－Abstract：We propose the diffractive optical element using the sub－ wavelength scale pillar array structure．The equivalent macroscopic refractive index can be controlled by changing pillar width and the pillar lattice constant．Advantages of using the sub－wavelength scale structure to manipulate the equivalent index in such a manner are that the optical functional elements can be fabricated by a single－etch－step process，and that the anisotropic optical characteristics can be realized using isotropic materials．In this paper，we have designed and fabricated the Fresnel lens with sub－wavelength structure on the Si substrate．The equivalent refractive index，neff，as a function of the pillar width and the lattice constant was calculated by the EMT（Effective Medium Theory）．The width of pillar at the $n$－th lattice point，an，was determined by neff and required the local optical length of the target diffractive optical element． The design wavelength，？，was set at 1.6 ？m，the lattice constant，？，was 0.45 ？m，the pillar height，h，was $1.21 ? \mathrm{~m}$ ，and the refractive index of Si ， nsi，was 3.48 ，respectively．These parameter values satisfied the sub－ wavelength condition of ？$>$ nsi $\times$ ？．The Fresnel lens with a focal length of 20 mm and the effective diameter of 1.8 mm was designed and fabricated．


